

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	5436	((electrostatic) near3 (clamp\$4 or force)) and electrode and dielectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/09/08 13:35
L2	7197	((electrostatic) near3 (clamp\$4 or force)) and electrode and dielectric	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 13:35
L3	5863	2 and (article or substrate or wafer or reticle or mask)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 13:41
L4	295	3 and (electrostatic near6 (mov\$4 or driv\$4) near5 (substrate or wafer or reticle or mask or article))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 13:51
L5	191	4 and (electrostatic near7 ((mov\$4 or driv\$4 or transport\$4 or convey\$4) near4 (substrate or reticle or mask or article or object or target)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 13:55
L6	39	5 and ("361"/\$.cccls. or "355"/\$.cccls. or "378"/\$.cccls. or "310"/\$.cccls. or "318"/\$.cccls.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 14:01
L7	426	("20020008954" "20020101956" "20020109954" "20020145714" "20030155080" "20040012767" "4522489" "4969168" "5315473" "5413360" "5436790" "5530616" "5583786" "5610683" "5838529" "5880922" "6055150" "6075375" "6134096" "6169652" "6185085" "6215642" "6351367" "6361313" "6377060" "6404483" "6480369" "6522519" "6556414" "6606234" "6721035" "6839217")".PN"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 14:01
L8	206	7 and ("361"/\$.cccls. or "355"/\$.cccls. or "378"/\$.cccls. or "310"/\$.cccls. or "318"/\$.cccls.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 15:19

## EAST Search History

L9	0	(((\$4lithograph\$4) and (electrode) and (dielectric adj3 (layer)) and (electrostatic near7 (provid\$4 or integral\$4) near6 (support\$4 or base or chuck or position\$4)) and ((mov\$4 or driv\$4 or remov\$4) near5 (substrate or article or reticle or mask or object))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 15:28
L10	0	(\$6lithograph\$4 and (handler same (provid\$4 or position\$4 or intergrat\$4) near5 (chuck or base or support\$4)) and electrostatic\$4 and dielectric and ((mov\$4 or remov\$4 or driv\$4) near5 (reticle or mask or substrate or wafer or article or object))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 15:34
L11	1	((((article or substrate or reticle or mask) near4 (handler)) near4 (provid\$4 or position\$4 or support\$4) and detect\$4 near5 (presence or absence) near4 (substrate or wafer or reticle or mask) and (electrostatic\$4 near4 clamp\$4)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/08 16:29